

#3

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of)
 Toshio Endo et al.) Group:
 Serial No.)
 Filed:) Examiner:
 Title: LIQUID CARBOXY-CONTAINING)
 POLYESTER OLIGOMER, A WATER-COMPATIBLE)
 POLYURETHANE RESIN, AND PROCESS FOR)
 PRODUCING THE SAME)

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
 P.O. Box 1450
 Alexandria, VA 22313-1450

Sir:

Applicants wish to bring to the attention of the Examiner the document identified on the attached form PTO-1449. Applicants respectfully request that this document be made of record in the present application.

REMARKS:

JP 11-349915 is cited in an International Search Report dated October 7, 2003 in PCT/JP03/011148.

If any fees are necessary in connection with this document, or insufficient fees are sent herewith, please charge Deposit Account No. 02-0385, Baker & Daniels.

Respectfully submitted,

John F. Hoffman
 Registration No. 26,280
 Attorney for Applicant

JFH/pmp

BAKER & DANIELS
 Suite 800
 111 East Wayne Street
 Fort Wayne, IN 46802
 Telephone: 260-424-8000
 Facsimile: 260-460-1700

Enc. Form PTO-1449
 Cited Reference

Date: March 1, 2005

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

Docket Number (Optional)
YOS00

Application Number

Applicant(s)
Toshio Endo et al.

Filing Date

Group Art Unit

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
		11-349915	12/1999	Japan (*)			✓	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

		(*) = English language abstract only

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.